Fernando A. Ponce

List of Publications by Year in descending order

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354 papers

13,122 citations

55 h-index 104 g-index

357 all docs

357 docs citations

357 times ranked

8509 citing authors

#	Article	IF	Citations
1	Realizing crack-free high-aluminum-mole-fraction AlGaN on patterned GaN beyond the critical layer thickness. Journal of Applied Physics, 2022, 131, .	1.1	5
2	Nanostructured materials for high efficiency solar cells. , 2021, , 201-227.		1
3	The impact of interfacial Si contamination on GaN-on-GaN regrowth for high power vertical devices. Applied Physics Letters, 2021, 118, .	1.5	14
4	Selective area regrowth and doping for vertical gallium nitride power devices: Materials challenges and recent progress. Materials Today, 2021, 49, 296-323.	8.3	21
5	Characterization of MOCVD regrown p-GaN and the interface properties for vertical GaN power devices. Semiconductor Science and Technology, 2021, 36, 014005.	1.0	3
6	High Voltage Vertical GaN p-n Diodes With Hydrogen-Plasma Based Guard Rings. IEEE Electron Device Letters, 2020, 41, 127-130.	2.2	49
7	Demonstration of GaN-based metal–insulator–semiconductor junction by hydrogen plasma treatment. Applied Physics Letters, 2020, 117, .	1.5	7
8	GaN Vertical-Channel Junction Field-Effect Transistors With Regrown p-GaN by MOCVD. IEEE Transactions on Electron Devices, 2020, 67, 3972-3977.	1.6	25
9	The effect of low-angle off-axis GaN substrate orientation on the surface morphology of Mg-doped GaN epilayers. Journal of Applied Physics, 2020, 128, 055301.	1.1	1
10	Lateral and vertical growth of Mg-doped GaN on trench-patterned GaN films. Applied Physics Letters, 2020, 117, .	1.5	14
11	Influence of substrate misorientation on the optical properties of Mg-doped GaN. Journal of Applied Physics, 2020, 127, .	1.1	3
12	Investigation of polycrystalline GaxIn1 â^' xP for potential use as a solar cell absorber with tunable bandgap. Journal of Applied Physics, 2020, 127, 073102.	1.1	3
13	Corrections to "Lateral Current Spreading in III-N Ultraviolet Vertical-Cavity Surface-Emitting Lasers Using Modulation-Doped Short Period Superlattices―[Aug 18 Art. no. 2400507]. IEEE Journal of Quantum Electronics, 2019, 55, 1-1.	1.0	1
14	Dopant profiling in <i>p-i-n</i> GaN structures using secondary electrons. Journal of Applied Physics, 2019, 126, .	1.1	19
15	Evaluating the performance of InGaN/GaN multi-quantum-well solar cells operated at elevated temperatures via DC and small-signal AC analysis. Japanese Journal of Applied Physics, 2019, 58, 101003.	0.8	2
16	Identification of point defects using high-resolution electron energy loss spectroscopy. Physical Review B, 2019, 99, .	1.1	6
17	Non-uniform Mg distribution in GaN epilayers grown on mesa structures for applications in GaN power electronics. Applied Physics Letters, 2019, 114, .	1.5	25
18	Novel semiconductors for sustainable solar energy technologies. Journal of Physics: Conference Series, 2019, 1173, 012001.	0.3	2

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19	Implantation-and etching-free high voltage vertical GaN p–n diodes terminated by plasma-hydrogenated p-GaN: revealing the role of thermal annealing. Applied Physics Express, 2019, 12, 051015.	1.1	28
20	Effect of InAs quantum dots capped with GaAs on atomic-scale ordering in GaO.5InO.5P. Journal of Applied Physics, 2019, 125, 053104.	1.1	2
21	Determination of electronic band structure by electron holography of etched-and-regrown interfaces in GaN <i>p-i-n</i> diodes. Applied Physics Letters, 2019, 115, .	1.5	12
22	Investigation of GaN-on-GaN vertical $\langle i \rangle p \langle i \rangle - \langle i \rangle n \langle i \rangle$ diode with regrown $\langle i \rangle p \langle i \rangle - GaN$ by metalorganic chemical vapor deposition. Applied Physics Letters, 2018, 113, .	1.5	52
23	Nonpolar vertical GaN-on-GaN p–n diodes grown on free-standing \$(10ar{1}0)\$ <i>m</i> plane GaN substrates. Applied Physics Express, 2018, 11, 111003.	1.1	13
24	Theory and Design of Electron Blocking Layers for III-N-Based Laser Diodes by Numerical Simulation. IEEE Journal of Quantum Electronics, 2018, 54, 1-11.	1.0	13
25	High Resolution EELS of Point Defects in a Nitride Semiconductor Material. Microscopy and Microanalysis, 2018, 24, 430-431.	0.2	0
26	Dislocation baskets in thick InxGa1â^'xN epilayers. Journal of Applied Physics, 2018, 124, .	1.1	3
27	CdCl2 passivation of polycrystalline CdMgTe and CdZnTe absorbers for tandem photovoltaic cells. Journal of Applied Physics, 2018, 123, .	1.1	26
28	Lateral Current Spreading in III-N Ultraviolet Vertical-Cavity Surface-Emitting Lasers Using Modulation-Doped Short Period Superlattices. IEEE Journal of Quantum Electronics, 2018, 54, 1-7.	1.0	16
29	100â€nm thick singleâ€phase wurtzite BAIN films with boron contents over 10%. Physica Status Solidi (B): Basic Research, 2017, 254, 1600699.	0.7	35
30	Sub 250 nm deep-UV AlGaN/AlN distributed Bragg reflectors. Applied Physics Letters, 2017, 110, .	1.5	29
31	Origin of high hole concentrations in Mgâ€doped GaN films. Physica Status Solidi (B): Basic Research, 2017, 254, 1600668.	0.7	17
32	Plasticity and optical properties of GaN under highly localized nanoindentation stress fields. Journal of Applied Physics, 2017, 121, .	1.1	28
33	Correlation between size distribution and luminescence properties of spool-shaped InAs quantum dots. Semiconductor Science and Technology, 2017, 32, 055013.	1.0	5
34	Refractory In $\{x\}$ Ga1â^' $\{x\}$ N Solar Cells for High-Temperature Applications. IEEE Journal of Photovoltaics, 2017, 7, 1646-1652.	1.5	26
35	Crystal structure and composition of BAIN thin films: Effect of boron concentration in the gas flow. Journal of Crystal Growth, 2017, 475, 334-340.	0.7	17
36	Stability of alloyed and nonalloyed ohmic contacts to n-type GaN at high temperature in air. Japanese Journal of Applied Physics, 2017, 56, 126502.	0.8	1

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37	A review of the synthesis of reduced defect density InxGa1â^'xN for all indium compositions. Solid-State Electronics, 2017, 136, 3-11.	0.8	19
38	High Reflectivity Hybrid AlGaN/Silver Distributed Bragg Reflectors for Use in the UV-Visible Spectrum. IEEE Journal of Quantum Electronics, 2017, 53, 1-8.	1.0	6
39	Growth and Characterization of III-N Ultraviolet Lasers and Avalanche Photodiodes by MOCVD., 2017,,		0
40	Local Strain Relaxation by A-type Dislocation Clusters in InxGal-xN/GaN Film with Indium Compositions of $x = 0.07$ and 0.12 . Microscopy and Microanalysis, 2016, 22, 1572-1573.	0.2	0
41	Critical thickness investigation of MBE-grown GalnAs/GaAs and GaAsSb/GaAs heterostructures. Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2016, 34, 02L113.	0.6	11
42	Improved optical properties of InAs quantum dots for intermediate band solar cells by suppression of misfit strain relaxation. Journal of Applied Physics, 2016, 120, .	1.1	15
43	Development of a high-band gap high temperature III-nitride solar cell for integration with concentrated solar power technology. , 2016, , .		9
44	Strain management of AlGaN-based distributed Bragg reflectors with GaN interlayer grown by metalorganic chemical vapor deposition. Applied Physics Letters, $2016,109,109$	1.5	14
45	AlGaSb based solar cells grown on GaAs by Molecular Beam Epitaxy. , 2016, , .		0
46	Optically pumped vertical-cavity surface-emitting laser at 374.9 nm with an electrically conducting n-type distributed Bragg reflector. Applied Physics Express, 2016, 9, 111002.	1.1	21
47	Temperature Dependence and High-Temperature Stability of the Annealed Ni/Au Ohmic Contact to p-Type GaN in Air. Journal of Electronic Materials, 2016, 45, 2087-2091.	1.0	10
48	Electrically conducting n-type AlGaN/GaN distributed Bragg reflectors grown by metalorganic chemical vapor deposition. Journal of Crystal Growth, 2016, 443, 81-84.	0.7	14
49	Development for ultraviolet vertical cavity surface emitting lasers. Proceedings of SPIE, 2016, , .	0.8	3
50	Early nucleation stages of low density InAs quantum dots nucleation on GaAs by MOVPE. Journal of Crystal Growth, 2016, 434, 47-54.	0.7	6
51	A new exposure model to evaluate smoked illicit drugs in rodents: A study of crack cocaine. Journal of Pharmacological and Toxicological Methods, 2016, 77, 17-23.	0.3	8
52	Onset of deep UV surface stimulated emission from AlGaN multiple quantum wells., 2016,,.		0
53	Growth of single-phase wurtzite BAIN with 7.2%-B contents. , 2016, , .		0
54	Growth of III-Nitrides. Physica Status Solidi C: Current Topics in Solid State Physics, 2015, 12, 331-333.	0.8	0

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55	Effect of Group-III precursors on unintentional gallium incorporation during epitaxial growth of InAlN layers by metalorganic chemical vapor deposition. Journal of Applied Physics, 2015, 118, .	1.1	5
56	Onset of surface stimulated emission at 260 nm from AlGaN multiple quantum wells. Applied Physics Letters, 2015, 107, .	1.5	24
57	Growth of highâ€quality AlN layers on sapphire substrates at relatively low temperatures by metalorganic chemical vapor deposition. Physica Status Solidi (B): Basic Research, 2015, 252, 1089-1095.	0.7	46
58	Strain Relaxation in InAs Quantum Dots and its Suppression by Indium Flushing. Microscopy and Microanalysis, 2015, 21, 983-984.	0.2	0
59	Structural and Optical Properties of AlGaN MQWs Grown by MOCVD Using One and Two TMG Sources. Microscopy and Microanalysis, 2015, 21, 1681-1682.	0.2	0
60	High Spatial/Energy Resolution Band Gap Measurements: Delocalization and Other Effects in a Monochromated Cold FEG Nion Dedicated STEM. Microscopy and Microanalysis, 2015, 21, 657-658.	0.2	1
61	Optically pumped low-threshold UV lasers. , 2015, , .		0
62	From InAs extended monolayer flat 2D terraces to 3D islands grown on GaAs substrates. , 2015, , .		0
63	III-nitride deep UV laser on sapphire substrate. , 2015, , .		0
64	Temperature dependence of the crystalline quality of AlN layer grown on sapphire substrates by metalorganic chemical vapor deposition. Journal of Crystal Growth, 2015, 414, 76-80.	0.7	38
65	Low-temperature growth of InGaN films over the entire composition range by MBE. Journal of Crystal Growth, 2015, 425, 115-118.	0.7	36
66	Demonstration of transverse-magnetic deep-ultraviolet stimulated emission from AlGaN multiple-quantum-well lasers grown on a sapphire substrate. Applied Physics Letters, 2015, 106, .	1.5	53
67	Inverse-Tapered p-Waveguide for Vertical Hole Transport in High-[Al] AlGaN Emitters. IEEE Photonics Technology Letters, 2015, 27, 1768-1771.	1.3	9
68	Comprehensive study of the electronic and optical behavior of highly degenerate p-type Mg-doped GaN and AlGaN. Journal of Applied Physics, 2015, 117 , .	1.1	49
69	Low-threshold stimulated emission at 249 nm and 256 nm from AlGaN-based multiple-quantum-well lasers grown on sapphire substrates. Applied Physics Letters, 2014, 105, .	1.5	78
70	Simulations, Practical Limitations, and Novel Growth Technology for InGaN-Based Solar Cells. IEEE Journal of Photovoltaics, 2014, 4, 601-606.	1.5	28
71	(Invited) Carrier Dynamics and Photon Management for Improvement in Quantum Efficiencies of GaN-Based Visible Light-Emitting Diodes. ECS Transactions, 2014, 61, 109-116.	0.3	0
72	Optically pumped deep-ultraviolet AlGaN multi-quantum-well lasers grown by metalorganic chemical vapor deposition., 2014,,.		3

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73	High Energy and Spatial Resolution EELS Band Gap Measurements Using a Nion Monochromated Cold Field Emission HERMES Dedicated STEM. Microscopy and Microanalysis, 2014, 20, 70-71.	0.2	2
74	Optically pumped AlGaN quantumâ€well lasers at subâ€250 nm grown by MOCVD on AlN substrates. Physica Status Solidi C: Current Topics in Solid State Physics, 2014, 11, 258-260.	0.8	13
75	Origins of unintentional incorporation of gallium in InAlN layers during epitaxial growth, part II: Effects of underlying layers and growth chamber conditions. Journal of Crystal Growth, 2014, 388, 143-149.	0.7	44
76	InAs quantum dot growth on Al <i>x</i> Galâ^' <i>x</i> As by metalorganic vapor phase epitaxy for intermediate band solar cells. Journal of Applied Physics, 2014, 116, .	1.1	17
77	Compositional variations in In _{0.5} Ga _{0.5} N nanorods grown by molecular beam epitaxy. Nanotechnology, 2014, 25, 215705.	1.3	9
78	Origins of unintentional incorporation of gallium in AllnN layers during epitaxial growth, part I: Growth of AllnN on AlN and effects of prior coating. Journal of Crystal Growth, 2014, 388, 137-142.	0.7	45
79	A Hybrid Concentrating Solar Thermal/ Photovoltaic System Using a High Temperature III-nitride Photovoltaic Device. , 2014, , .		0
80	Room-temperature optically pumped AlGaN-AlN multiple-quantum-well lasers operating at <260nm grown by metalorganic chemical vapor deposition. Proceedings of SPIE, 2013, , .	0.8	1
81	Deep-ultraviolet lasing at 243 nm from photo-pumped AlGaN/AlN heterostructure on AlN substrate. Applied Physics Letters, 2013, 102, .	1.5	77
82	Sub-250 nm low-threshold deep-ultraviolet AlGaN-based heterostructure laser employing HfO2/SiO2 dielectric mirrors. Applied Physics Letters, 2013, 103, .	1.5	36
83	Highly luminescent, high-indium-content InGaN film with uniform composition and full misfit-strain relaxation. Applied Physics Letters, 2013, 103, .	1.5	35
84	Improved Hole Transport by ${m p}hbox{-}{m ln}_{x}{m Ga}_{1-x}{m N}$ Layer in Multiple Quantum Wells of Visible LEDs. IEEE Photonics Technology Letters, 2013, 25, 1789-1792.	1.3	2
85	The effect of InGaN underlayers on the electronic and optical properties of InGaN/GaN quantum wells. Applied Physics Letters, 2013, 102, .	1.5	19
86	The growth of In0.5Ga0.5N and InN layers on (111)Si using nanorod intermediate arrays. Journal of Crystal Growth, 2013, 384, 55-60.	0.7	2
87	Indium Nitride and Indium Gallium Nitride layers grown on nanorods. Journal of Physics: Conference Series, 2013, 471, 012025.	0.3	1
88	Capacitance Voltage Characteristics and Electron Holography on Cubic AlGaN/GaN Heterojunctions. Japanese Journal of Applied Physics, 2013, 52, 08JN04.	0.8	9
89	The effect of nanoscratching direction on the plastic deformation and surface morphology of InP crystals. Journal of Applied Physics, 2013, 114, .	1.1	5
90	Hydrogen-related, deeply bound excitons in Mg-doped GaN films. Applied Physics Letters, 2013, 103, 082103.	1.5	12

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91	Strain-related optical properties of ZnO crystals due to nanoindentation on various surface orientations. Journal of Applied Physics, 2013, 113, 183511.	1.1	14
92	Stimulated emission at 257 nm from optically-pumped AlGaN/AlN heterostructure on AlN substrate. Physica Status Solidi (A) Applications and Materials Science, 2013, 210, 1768-1770.	0.8	7
93	Early stages of mechanical deformation in indium phosphide with the zinc blende structure. Journal of Applied Physics, 2012, 112, 063514.	1.1	9
94	Correlated Structural, Electronic, and Optical Properties of AlN/GaN Multiple Quantum Disks in GaN Nanowires. Applied Physics Express, 2012, 5, 025001.	1.1	6
95	Free carrier accumulation at cubic AlGaN/GaN heterojunctions. Applied Physics Letters, 2012, 100, 142108.	1.5	11
96	Efficiency droop due to electron spill-over and limited hole injection in III-nitride visible light-emitting diodes employing lattice-matched InAlN electron blocking layers. Applied Physics Letters, 2012, 101, .	1.5	80
97	Compositional instability in InAlN/GaN lattice-matched epitaxy. Applied Physics Letters, 2012, 100, .	1.5	30
98	Microstructure and polarization fields in nitride semiconductors. Journal of Physics: Conference Series, 2011, 326, 012001.	0.3	1
99	Microstructure of nanoscratched semiconductors. Journal of Physics: Conference Series, 2011, 326, 012061.	0.3	0
100	Plastic hardening in cubic semiconductors by nanoscratching. Journal of Applied Physics, 2011, 109, 013502.	1.1	5
101	Transmission electron microscopy study of GalnNAs(Sb) thin films grown by atomic hydrogen-assisted molecular beam epitaxy. Applied Physics Letters, 2011, 99, 191907.	1.5	14
102	Ammonothermal growth of high-quality GaN crystals on HVPE template seeds. Journal of Crystal Growth, 2011, 318, 1030-1033.	0.7	17
103	Electrostatic energy profiles at nanometerâ€scale in group III nitride semiconductors using electron holography. Annalen Der Physik, 2011, 523, 75-86.	0.9	13
104	Performance characteristics of InAlGaN laser diodes depending on electron blocking layer and waveguiding layer design grown by metalorganic chemical vapordeposition. Journal of Crystal Growth, 2011, 315, 272-277.	0.7	8
105	Optimization of growth conditions for InGaAs/InAlAs/InP quantum cascade lasers by metalorganic chemical vapor deposition. Journal of Crystal Growth, 2011, 316, 75-80.	0.7	24
106	High quality a-plane GaN films grown on cone-shaped patterned r-plane sapphire substrates. Thin Solid Films, 2011, 519, 2508-2512.	0.8	9
107	Reduction of structural defects in a-plane GaN epitaxy by use of periodic hemispherical patterns in r-plane sapphire substrates. Journal of Vacuum Science and Technology B:Nanotechnology and Microelectronics, 2011, 29, 021005.	0.6	2
108	Effect of misfit dislocations on luminescence in m-plane InGaN quantum wells. Applied Physics Letters, 2011, 98, 261914.	1.5	15

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109	Performance improvement of InGaN-based laser diodes by epitaxial layer structure design. Proceedings of SPIE, 2010, , .	0.8	3
110	Inâ€plane polarization of GaNâ€based heterostructures with arbitrary crystal orientation. Physica Status Solidi (A) Applications and Materials Science, 2010, 207, 2226-2232.	0.8	19
111	Polarization effects in 2-DEG and 2-DHG AlGaN/AlN/GaN multi-heterostructures measured by electron holography. Physica Status Solidi (B): Basic Research, 2010, 247, 1722-1724.	0.7	6
112	Preface: Phys. Status Solidi C 7/1. Physica Status Solidi C: Current Topics in Solid State Physics, 2010, 7, 7-8.	0.8	5
113	Effect of Growth Temperature on the Electron-Blocking Performance of InAlN Layers in Green Emitting Diodes. Applied Physics Express, 2010, 3, 031003.	1.1	5
114	Strain Relaxation Mechanisms in AlGaN Epitaxy on AlN Templates. Applied Physics Express, 2010, 3, 111003.	1.1	20
115	Growth of linearly ordered arrays of InAs nanocrystals on scratched InP. Journal of Applied Physics, 2010, 107, 054313.	1.1	5
116	Improvement of peak quantum efficiency and efficiency droop in III-nitride visible light-emitting diodes with an InAlN electron-blocking layer. Applied Physics Letters, 2010, 96, .	1.5	183
117	Carrier localization and nonradiative recombination in yellow emitting InGaN quantum wells. Applied Physics Letters, 2010, 96, .	1.5	52
118	Improvement of quantum efficiency by employing active-layer-friendly lattice-matched InAlN electron blocking layer in green light-emitting diodes. Applied Physics Letters, 2010, 96, .	1.5	89
119	Misfit strain relaxation in m-plane epitaxy of InGaN on ZnO. Applied Physics Letters, 2010, 96, .	1.5	6
120	Donor-related cathodoluminescence of p-AlGaN electron blocking layer embedded in ultraviolet laser diode structure. Applied Physics Letters, 2009, 94, 211103.	1.5	1
121	Nanoscale dislocation patterning by scratching in an atomic force microscope. Journal of Applied Physics, 2009, 106, 076106.	1.1	8
122	Evidence of Two-Dimensional Hole Gas in p-Type AlGaN/AlN/GaN Heterostructures. Applied Physics Express, 2009, 2, 121001.	1.1	13
123	Comparative Study on MOCVD Growth of a-Plane GaN Films on r-Plane Sapphire Substrates Using GaN, AlGaN, and AlN Buffer Layers. Journal of Electronic Materials, 2009, 38, 1938-1943.	1.0	21
124	Preface: Phys. Status Solidi A 206/2. Physica Status Solidi (A) Applications and Materials Science, 2009, 206, 193-194.	0.8	0
125	Measurement of the solubility of ammonia and nitrogen in gallium at atmospheric pressure. Journal of Alloys and Compounds, 2009, 467, 611-613.	2.8	5
126	Highly conductive modulation doped composition graded p-AlGaN/(AlN)/GaN multiheterostructures grown by metalorganic vapor phase epitaxy. Journal of Applied Physics, 2009, 106, .	1.1	17

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127	SEM characterization of silicon nanostructures: can we meet the challenge?. Scanning, 2008, 30, 310-316.	0.7	5
128	Synthesis and luminescence properties of ZnO nanostructures produced by the sol–gel method. Journal of Crystal Growth, 2008, 310, 599-603.	0.7	64
129	Growth of free-standing highly luminescent undoped and Mg-doped GaN thick films with a columnar structure. Journal of Crystal Growth, 2008, 310, 3131-3134.	0.7	9
130	Surface morphology control of green LEDs with p-InGaN layers grown by metalorganic chemical vapor deposition. Journal of Crystal Growth, 2008, 310, 5166-5169.	0.7	6
131	Control of quantum-confined Stark effect in InGaNâ^•GaN multiple quantum well active region by p-type layer for III-nitride-based visible light emitting diodes. Applied Physics Letters, 2008, 92, .	1.5	60
132	Blue light emitting diodes grown on freestanding (11-20) a-plane GaN substrates. Applied Physics Letters, 2008, 92, 011123.	1.5	26
133	Time-resolved cathodoluminescence of Mg-doped GaN. Applied Physics Letters, 2008, 93, .	1.5	19
134	Effect of native oxide mechanical deformation on InP nanoindentation. Journal of Applied Physics, 2008, 104, .	1.1	10
135	Photoluminescence of near-lattice-matched GaNâ^•AlInN quantum wells grown on free-standing GaN and on sapphire substrates. Applied Physics Letters, 2008, 92, .	1.5	7
136	Role of the buffer layer thickness on the formation of basal plane stacking faults in a-plane GaN epitaxy on r-sapphire. Applied Physics Letters, 2008, 93, 011901.	1.5	24
137	Structural and optical properties of nonpolar GaN thin films. Applied Physics Letters, 2008, 92, .	1.5	61
138	Determination of the electronic band structure for a graded modulation-doped AlGaNâ^•AlNâ^•GaN superlattice. Applied Physics Letters, 2007, 91, 142121.	1.5	9
139	Basal-plane slip in InGaNâ^•GaN heterostructures in the presence of threading dislocations. Applied Physics Letters, 2007, 90, 171922.	1.5	13
140	Mapping the electrostatic potential across AlGaNâ [•] -AlNâ [•] -GaN heterostructures using electron holography. Applied Physics Letters, 2007, 90, 032101.	1.5	26
141	Atomic force nanolithography of InP for site control growth of InAs nanostructures. Applied Physics Letters, 2007, 90, 013117.	1.5	12
142	Effect of internal electrostatic fields in InGaN quantum wells on the properties of green light emitting diodes. Applied Physics Letters, 2007, 91, .	1.5	25
143	Optical properties of highly luminescent zinc oxide tetrapod powders. Applied Physics Letters, 2007, 91, 121905.	1.5	21
144	Metal–Organic Hydride Vapor Phase Epitaxy of AlxGa1-xN Films over Sapphire. Japanese Journal of Applied Physics, 2007, 46, L752-L754.	0.8	23

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145	TEM Characterization of ZnO Crystals Synthesize with Controlled Size and Morphology. Microscopy and Microanalysis, 2007, 13, .	0.2	O
146	Synthesis of highly luminescent, undoped, Mg-doped and Si-doped GaN powders. Journal of Crystal Growth, 2007, 304, 225-232.	0.7	9
147	Dislocation generation at the coalescence of aluminum nitride lateral epitaxy on shallow-grooved sapphire substrates. Applied Physics Letters, 2007, 90, 221909.	1.5	27
148	Correlation of spectral luminescence with threading dislocations in green-light-emitting InGaN quantum wells. Applied Physics Letters, 2007, 90, 231901.	1.5	17
149	AlxGa1â^'xN (0⩽x⩽1) nanocrystalline powder by pyrolysis route. Journal of Crystal Growth, 2007, 308, 198-203.	0.7	5
150	Growth of InAs nanostructures on InP using atomic-force nanolithography. Applied Physics A: Materials Science and Processing, 2007, 89, 945-949.	1.1	7
151	Misfit Dislocation Generation in InGaN Epilayers on Free-Standing GaN. Japanese Journal of Applied Physics, 2006, 45, L549-L551.	0.8	38
152	Pulsed lateral epitaxial overgrowth of aluminum nitride on sapphire substrates. Applied Physics Letters, 2006, 89, 081905.	1.5	79
153	Carrier dynamics and electrostatic potential variation in InGaN quantum wells grown on {112¯2} GaN pyramidal planes. Applied Physics Letters, 2006, 89, 231908.	1.5	10
154	Structure and luminescence of nanocrystalline gallium nitride synthesized by a novel polymer pyrolysis route. Optical Materials, 2006, 29, 19-23.	1.7	15
155	Optical Properties of GaN Nanowhiskers Produced by Photoelectrochemical Etching. ECS Transactions, 2006, 3, 415-419.	0.3	4
156	Generation of misfit dislocations by basal-plane slip in InGaNâ^•GaN heterostructures. Applied Physics Letters, 2006, 89, 201911.	1.5	61
157	Prismatic stacking faults in epitaxially laterally overgrown GaN. Applied Physics Letters, 2006, 88, 141912.	1.5	69
158	Growth of InN on Ge substrate by molecular beam epitaxy. Journal of Crystal Growth, 2005, 279, 311-315.	0.7	14
159	CBED study of grain misorientations in AlGaN epilayers. Ultramicroscopy, 2005, 103, 23-32.	0.8	0
160	Influence of stacking faults on the properties of GaN-based UV light-emitting diodes grown on non-polar substrates. Physica Status Solidi C: Current Topics in Solid State Physics, 2005, 2, 2732-2735.	0.8	11
161	Electrostatic Fields and Compositional Fluctuations in InGaN Quantum Wells. AIP Conference Proceedings, 2005, , .	0.3	1
162	The Electronic Nature of metal/p-GaN Junctions. AIP Conference Proceedings, 2005, , .	0.3	0

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163	Localization versus carrier-screening effects in InGaN quantum wells $\hat{a} \in \text{``}$ A time-resolved cathodoluminescence study. AIP Conference Proceedings, 2005, , .	0.3	1
164	Crystal Structure of Low-Resistance Au-Ni/p-GaN Contacts. AIP Conference Proceedings, 2005, , .	0.3	1
165	Deep green emission at 570nm from InGaN/GaN MQW active region grown on bulk AlN substrate. , 2005, 5941, 37.		2
166	The Nature of Crystalline Defects in a-plane GaN Films. AIP Conference Proceedings, 2005, , .	0.3	0
167	Light Emission from GaN Microcrystals. AIP Conference Proceedings, 2005, , .	0.3	O
168	Optoelectronic and microstructure attributes of epitaxial SrTiO3 on Si. Journal of Applied Physics, 2005, 97, 014101.	1.1	25
169	Polychromatic light emission from single InGaN quantum wells grown on pyramidal GaN facets. Applied Physics Letters, 2005, 87, 131911.	1.5	44
170	Fine structure of AlNâ-AlGaN superlattice grown by pulsed atomic-layer epitaxy for dislocation filtering. Applied Physics Letters, 2005, 87, 211915.	1.5	49
171	A Novel Method to Synthesize Blue-Luminescent Doped GaN Powders. Materials Research Society Symposia Proceedings, 2005, 864, 6101.	0.1	2
172	Strain Relaxation Mechanisms in InGaN Epilayers. AIP Conference Proceedings, 2005, , .	0.3	0
173	Luminescence from stacking faults in gallium nitride. Applied Physics Letters, 2005, 86, 021908.	1.5	315
174	Nitrogen surfactant effects in GalnP. Journal of Applied Physics, 2004, 96, 7229-7234.	1.1	4
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